The effect of inter-valley scattering on weak localisation in graphene

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Abstract

We experimentally demonstrate that weak localisation (WL) exists in graphene fabricated by mechanical exfoliation at different carrier densities. We show that it is controlled not only by inelastic dephasing mechanisms, but also by elastic intra- and inter-valley scattering. By reducing the width of the graphene sample, inter-valley scattering is found to be limited by the sample boundaries. Intravalley scattering, which suppresses WL in one valley, is found to be much faster than inter-valley scattering. In the Dirac point, where there is a zero-net carrier density, we observe a distinct change in both elastic and inelastic scattering.

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1. Introduction

One of the simplest ways to observe directly the wave-like nature of electrons has been to measure the weak localisation (WL) correction to the conductivity of a two-dimensional conductor. Detailed analysis of this effect, originating from the interference of electrons on closed trajectories, has proved to be valuable way to extract information about the inelastic scattering mechanisms that underlie dephasing in charge transport. It has been shown [1,2] that WL in the recently discovered two-dimensional system, graphene [3], cannot only provide information about the dephasing but also elastic scattering mechanisms [4,5].

Elastic scattering in graphene occurs both within a single valley (intra-valley) and between valleys (inter-valley). It affects WL due to the pseudospin quantum number defining the carrier wavefunction in graphene—a result of the chiral property of the honeycomb crystal structure. The pseudospin behaves in a similar way to conventional spin in that it controls the phase of the wavefunction, and hence affects WL. The intra-valley effects that suppress WL are “chirality-breaking” scattering, which can occur off lattice dislocations and other topological defects [6,7], and the “trigonal warping” of the Fermi surface [4]. Inter-valley scattering, from atomically sharp defects, restores WL, both by allowing chirality-conserving scattering events to occur and by effectively symmetrizing the Fermi surface.

The WL correction to the conductivity of graphene is [4]

\[
\delta \sigma(B) = \frac{e^2}{4\pi \hbar} \left\{ \mathcal{F} \left( \frac{B}{B_0} \right) - \mathcal{F} \left( \frac{B}{B_0 + 2B_i} \right) - 2\mathcal{F} \left( \frac{B}{B_0 + B_i + B_z} \right) \right\}^2,
\]

where \( \mathcal{F}(x) = \ln(x) + \Psi(1/x) \), \( B_{0,i,z} = (\hbar/4De)^{-1} \), and the intravalley scattering rates \( \tau_{i}^{-1} = \tau_{w}^{-1} + \tau_{z}^{-1} \). Here \( \tau_{i}^{-1} \) is the inter-valley scattering rate, \( \tau_{z}^{-1} \) is the chirality-breaking, and \( \tau_{w}^{-1} \) the trigonal-warping rates. At low fields we see experimentally a positive magnetoconductivity followed by a saturation or down-turn at higher fields, and thus we infer from Eq. (1) that both \( \tau_{i}^{-1} \) and \( \tau_{s}^{-1} \) are significant scattering rates in graphene.

In a system free from atomically sharp scatterers, \( \tau_{i}^{-1} \) is necessarily limited by the physical boundaries of the graphene system, and \( \tau_{s}^{-1} \) must have an upper limit of \( \tau_{p}^{-1} \). The momentum relaxation rate \( \tau_{p}^{-1} \) is determined by impurities from the silica substrate [4] (i.e. a smooth potential) which does not affect the chirality.
2. Experiment

The graphene flakes were produced by the process of mechanical exfoliation [3]. They were deposited on an n⁺ Si wafer coated with 300 nm SiO₂. Lithographically defined Au/Cr contacts were then made to each flake. The resistance of the devices was measured by a standard lock-in technique in the temperature range 0.25–20 K in a perpendicular magnetic field. We consider here two samples, B and F2: B is a long ribbon of length \( L = 3.7 \mu m \) and width \( W = 0.3 \mu m \); F2 is the same length as B, but wider with \( W = 1.8 \mu m \).

The resistivity of each sample as a function of carrier density (controlled by the gate voltage \( V_g \)) is shown in Fig. 1. The samples are sufficiently small such that reproducible mesoscopic fluctuations of the conductance occur in all ranges of carrier density. To analyse WL we average the data over a large number of these fluctuations (\( \Delta V_g = 2V \)) to suppress their influence [1].

A fit of Eq. (1) to the magnetoconductivity data of sample F2 shows excellent agreement for all carrier densities, including the Dirac region, Fig. 2. The lengths \( L_i \) and \( L_\nu \) (\( L_i^2 = D \tau_i \), where \( D \) is the diffusion coefficient) extracted from the fit are \( T \)-independent over the whole temperature range. Also, we find for all densities that \( L_i \gg L_\nu \). The inter-valley scattering length appears to be limited by the width of the sample, \( L_\nu / W \approx 0.5 \). In contrast, \( L_\nu \approx l \), the mean free path, and is therefore not controlled by the same mechanisms as the inter-valley scattering. This argument is strengthened when it is seen that in the Dirac point \( L_i \) is suppressed whereas \( L_\nu \) is enhanced, Fig. 2(a).

The dephasing length \( L_\varphi \) is also affected by the geometry of the sample at low temperatures as the sample boundaries limit the size of the trajectories that can contribute to WL. The temperature dependence of \( L_\varphi \) is seen to be significantly suppressed for \( T < 3 \, \text{K} \) as these geometric limits are approached. (The high temperature data are discussed elsewhere [2].)

The magnetoconductivity of sample B has a significantly different shape to that of F2, Fig. 3. As the zero-field conductivity (and hence mean free path and diffusion coefficient) are comparable, \( L_\varphi \) in both samples should also be of similar size; this is seen experimentally, Fig. 3(a). The very strong WL correction in B (Fig. 3(b)), which shows less saturation and no downturn, must therefore be the result of fast inter-valley scattering. As \( L_i \) is limited by the width in sample F2, we can expect a much smaller value of \( L_i \approx 0.1-0.2 \, \mu m \) in sample B. However, to make the comparison we must be sure we are dealing with 2D and not 1D WL due to the small width of sample B.

For 1D WL analysis we must satisfy the condition \( W \ll L_\varphi \) [4], and \( B \ll h/eW^2 \approx 7 \, \text{mT} \). If we attempt to fit the 1D expression, \( \delta \sigma_{1D} = -2e^2L_\varphi/h(1+(\tau_i^{-2}/3\tau_\nu^{-1}\tau_W^{-1}))^{1/2} - 1 \), where \( \tau_i^{-1} = D/W^2 \) and assuming that \( L_i \to 0 \), we find good agreement even for much stronger fields, Fig. 3(b). Indeed, if we allow \( W \) as a free fitting parameter we find

![Fig. 1. Resistivity of samples B1 (a) and F2 (b) at \( T = 0.25 \, \text{K} \) as a function of carrier density. The inset shows electron micrographs of sample B1 (left) and F2 (right) with the positions of the contacts shown as outlines.](image1)

![Fig. 2. Weak localisation in sample F2. (a) Dependence of characteristic lengths on carrier density (the value of \( L_\nu \) is the saturation value at low temperatures). The dotted lines are guides to the eye. The crosses show the corresponding values of \( l \). (b) Examples of the fit (solid lines) of the magnetoconductivity data (symbols) at high carrier density (\( V_g = 10 \, \text{V} \)) to Eq. (1).](image2)
of inhomogeneity in the narrow sample thus appears to have a much more dramatic effect on the interference.

In both samples, $L_s$ tends to approach the mean free path. The decrease in $L_s$ with increasing carrier density seen in F2 suggests that trigonal-warping, rather than chirality-breaking, can be the main source of intra-valley scattering: it is expected that $\tau_w^{-1} \propto \tau_{nr}^2$ [4]. However, rough estimation shows that trigonal-warping is too weak to account for such a small $L_s$. Intra-valley scattering thus has a topological origin and can be the result of ripples or dislocations in the graphene layer. Since $L_s \sim W \gg L_i$ in this sample, the origin cannot lie in atomically sharp scatterers within the layer or the sample boundaries. (The reason for the enhancement of inter-valley scattering and slight suppression of intra-valley scattering in the Dirac region of sample F2 is unclear, but also indicates that the inter- and intra-valley scattering mechanisms are different.)

In sample B the difference between $L_i$ and $L_s$ is much smaller. For this sample $L_s/W \sim 0.3$, from which we conclude that inter-valley scattering occurs off both the sample boundaries and additional sharp scatterers in the bulk. (We have identified these scatterers as pronounced ridges that extend across the sample width [2]. A small value of $L_i$ with respect to the system size is also seen in Ref. [8], which can be attributed to additional scattering in the bulk.) The same scattering events can also break chirality, and this can account for the similar values of $L_i$ and $L_s$ seen in the experiment.

4. Conclusion

We have shown that WL occurs in graphene systems at all carrier densities, including the Dirac region where the net carrier density is zero. The intra- and inter-valley scattering were shown to affect the WL by causing a saturation and downturn of its magnetic field dependence. Inter-valley scattering is limited by the width of the graphene system. Intra-valley scattering is shown to have a topological origin and in a narrow sample can also be affected by the width. An increase of the dephasing rate in the Dirac region seen by the WL indicates an onset of inhomogeneity in graphene conduction in this region.

References